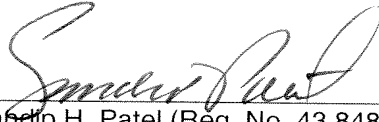


IN THE UNITED STATES PATENT
AND TRADEMARK OFFICE

Applicants:	Geun Su Lee et al.)	I hereby certify that this paper (along with
)	any paper referred to as being attached or
Serial No.:	10/723,029)	enclosed) is being transmitted via EFS-
)	Web to the U.S. Patent and Trademark
Filed:	November 26, 2003)	Office on December 27, 2006 .
)	
Title:	Cleaning Solution for Photoresist)	
	and Method for Forming Pattern)	
	Using the Same)	
)	
Group Art Unit:	1751)	
)	
Examiner:	Gregory E. Webb)	 Sandip H. Patel (Reg. No. 43,848)
)	Attorney for Applicants
Attorney Docket No.:	30205/39714)	
)	

RESPONSE TO OFFICIAL ACTION

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, Virginia 22313-1450

Dear Sir:

This paper is presented in response to the non-final official action dated August 28, 2006.

A complete listing of the claims begins on page **2** of this paper.

Remarks begin on page **7** of this paper.